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## Contents

- v Authors
- vii Conference Committee

#### UV AND HIGHER ENERGY MATERIALS AND LIGHT SOURCES I

10351 05 A design of energy detector for ArF excimer lasers [10351-4]

#### UV AND HIGHER ENERGY MATERIALS AND LIGHT SOURCES II

10351 07 Performance stability of reflection-mode AlGaN photocathode under different preparation methods [10351-6]

#### UV AND HIGHER ENERGY MATERIALS AND LIGHT SOURCES III

- 10351 OB **Recent advances in metals for plasmonics applications in the UV range (Invited Paper)** [10351-10]
- 10351 0D Aluminum nanostructures for ultraviolet plasmonics (Invited Paper) [10351-12]

#### APPLICATIONS OF UV, DEEP UV, VACUUM UV, AND EXTREME UV PHOTONICS

10351 0G Changes in electronic states of molecules resulted from interactions in the condensed phase (Invited Paper) [10351-15]

## **Authors**

Numbers in the index correspond to the last two digits of the seven-digit citation identifier (CID) article numbering system used in Proceedings of SPIE. The first five digits reflect the volume number. Base 36 numbering is employed for the last two digits and indicates the order of articles within the volume. Numbers start with 00, 01, 02, 03, 04, 05, 06, 07, 08, 09, 0A, 0B...0Z, followed by 10-1Z, 20-2Z, etc.

Alcaraz de la Osa, R., OB Bai, Lujun, 05 Ehara, Masahiro, OG Everitt, H. O., OB Feng, Zebin, 05 Gérard, Davy, 0D González, F., OB Gutiérrez, Y., OB Han, Xiaoquan, 05 Hao, Guanghui, 07 Khlopin, Dmitry, 0D Martin, Jérôme, 0D Maurer, Thomas, 0D Moreno, F., OB Morisawa, Yusuke, 0G Ortiz, D., OB Ozaki, Yukihiro, 0G Plain, Jérôme, 0D Proust, Julien, OD Qian, Yunsheng, 07 Qiu, Yafeng, 07 Saiz, J. M., OB Sanz, J. M., OB Schuermans, Silvère, OD Tachibana, Shin, OG Ueno, Nami, 0G Zhang, Feifei, OD Zhang, Junju, 07 Zhang, Yijun, 07 Zhou, Yi, 05

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- UV and Higher Energy Materials and Light Sources I Yong-Hoon Cho, KAIST (Korea, Republic of)
- 2 UV and Higher Energy Materials and Light Sources II Xiaohang Li, King Abdullah University of Science and Technology (Saudi Arabia)
- 3 UV and Higher Energy Materials and Light Sources III Satoshi Kawata, Osaka University (Japan)
- 4 UV and Higher Energy Spectroscopy Fernando Moreno, Universidad de Cantabria (Spain)
- 5 Applications of UV, Deep UV, Vacuum UV, and Extreme UV Photonics **Fernando Moreno**, Universidad de Cantabria (Spain)
- 6 UV and Deep UV Biosensing and Analysis with UV and Higher Energy Photonics
  Gilles Lérondel, Université de Technologie de Troyes (France)